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Email: iplaw@volentine.comDate: January 23, 2006To: Examiner Novacek
U.S. Patent OfficeFax No: 571-273-8300

Ph. No:

From: Andrew J. Telesz, Jr.Subject: Serial No. 10/780,867
Our Ref. No.: OKI.3900No. of Pages (including cover): 10.....
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CERTIFICATE OF TRANSMISSION BY FACSIMILE (37 CFR 1.8)Applicant(s): **Kazuya Hizawa**

Docket No.

OKI.390C

Application No.

10/780,867

Filing Date

February 19, 2004

Examiner

C. Novacek

Group Art Unit

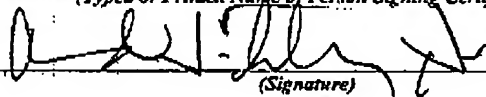
2822

Invention: **A METHOD FOR FABRICATING A SEMICONDUCTOR DEVICE HAVING A METALLIC SILICIDE LAYER**

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Request for Reconsideration*(Identify type of correspondence)*is being facsimile transmitted to the United States Patent and Trademark Office (Fax. No. 571-273-8300)

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Docket No.
OKI.390CTRANSMITTAL LETTER
(General - Patent Pending)

In Re Application Of: Kazuya Hizawa

Application No.
10/780,867Filing Date
February 19, 2004Examiner:
C. NovacekCustomer No.
20987Group Art Unit
2822Confirmation No.
1983

Title: A METHOD FOR FABRICATING A SEMICONDUCTOR DEVICE HAVING A METALLIC SILICIDE LAYER

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Request for Reconsideration

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Dated: January 23, 2006

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Serial No. 10/780,867
OKI.390C

Request for Reconsideration dated January 23, 2006

Via Facsimile 571-273-8300

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of

Kazuya Hizawa

Group Art Unit: 2822

Serial No.: 10/780,867

Examiner: C. Novacek

Filed: February 19, 2004

Confirm No.: 1983

For: A METHOD FOR FABRICATING A SEMICONDUCTOR DEVICE HAVING A
METALLIC SILICIDE LAYER

REQUEST FOR RECONSIDERATION

U.S. Patent and Trademark Office
Customer Window, Mail Stop AF
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Date: January 23, 2006

Sir:

In response to the Final Office Action dated November 8, 2005, the following
remarks are respectfully submitted in connection with the above-identified application.

Remarks/Arguments begin on page 2 of this paper.

Page 1 of 7

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